



Thematic Network on Silicon on Insulator Technology, Devices and Circuits.
[IST-1-506653-CA]

EUROSIO "Who is Who" Guide

Name of the organisation

<i>Organization Legal name:</i>	Institut für Mikroelektronik und Mechatronik Systeme gGmbH
<i>Organization short name:</i>	IMMS gGmbH
<i>Internet homepage:</i>	www.imms.de

Contact person

<i>Name:</i>	<i>Nuernbergk</i>	<i>Title:</i>	<i>Dr.-Ing.</i>
<i>First name:</i>	<i>Dirk</i>	<i>Sex:</i>	<i>M</i>
<i>Phone:</i>	<i>0049/361/6632520</i>	<i>E-mail:</i>	<i>dirk.nuernbergk@imms.de</i>
<i>Postal Address</i>	<i>Konrad-Zuse-Strasse 14</i>		

Other Senior Researchers: (up to 10 names, please include e-mail address)

Dipl.-Ing Stefan Bormann, stefan.bormann@imms.de

Dipl.-Ing. Sonja Richter, sonja.richter@imms.de

Dr.-Ing. Valentin Nakov, valentin.nakov@imms.de

Experience and expertise fields: (50 words)

Modelling of circuit elements of a partially depleted SOI technology, Analogue and digital circuit design of high temperature SOI circuits. Realised and measured circuits 10Bit ADC, DAC, Bandgap reference, voltage regulators, comparators, OpAmps (Analogue Library). HT-camshaft sensor, HT pressure sensor interface, SOI EEPROM circuit and cell design, SRAM,

Facilities and Equipment:

- Wafer prober with bridge, pulse measurement units, ICCAP for device measurements and modelling,
 - digital tester HP82000, thermo stream (T=-70..225°C), digital data analyser, spectrum analyser, network thermo chuck (T=-40..225°C), HP4155, low leakage switch matrix, LCR measurement analyser
 - RF measurements equipment up to 50 GHz, high frequency noise measurements, on wafer characterisation (8 inch wafer)
- Low frequency noise measurement equipment, on wafer characterisation (8 inch wafer)

Three last international research projects:

TERMIS - High temperature/ High-Voltage Mixed-Signal SOI ASICs for Aerospace Applications – ESPRIT: 29'598 (European commission) -

ATHIS - Advanced Techniques for High Temperature System-On-Chip - GRD1-2001-40707 (European commission)